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Suppleness formamidinium-based low-dimension perovskite derivative for sensitive and ultrastable X-Ray detection

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Abstract

Halide perovskite materials possess remarkable optoelectronic properties and have shown great potential for direct X-ray detection. Perovskite wafers are particularly attractive among various detection structures due to their scalability and ease of preparation, making them the most promising candidate for X-ray detection and array imaging applications. However, device instability and current drift caused by ionic migration is a persistent challenge for perovskite detectors, especially in polycrystalline wafers with numerous grain boundaries. In this study, we examined the potential of one-dimensional (1D) δ -phase (yellow phase) formamidinium lead iodide (δ -FAPbI₃) as an X-ray detection material. This material possesses a suitable band gap of 2.42 eV, which makes it highly promising for X-ray detection and imaging using compact wafers. Moreover, we found that δ -FAPbI₃ has low ionic migration, low Young's modulus, and excellent long-term stability, making it an ideal candidate for high-performance X-ray detection. Notably, the yellow phase perovskite derivative exhibit exceptional long-term atmospheric stability (RH of $\approx 70 \pm 5\%$) over six months, as well as an extremely low dark current drift ($3.43 \times 10^{-4} \text{ pA cm}^{-1} \text{ s}^{-1} \text{ V}^{-1}$), which is comparable to that of single crystal devices. An X-ray imager with a large size δ -FAPbI₃ wafer integrated on thin film transistor (TFT) backplane was further fabricated. Direct 2D multi-pixel radiographic imaging was successfully performed, demonstrating the feasibility of δ -FAPbI₃ wafer detectors for sensitive and ultra-stable imaging applications.

Introduction

Halide perovskites are considered one of the most promising materials for commercial direct X-ray detection due to their high X-ray conversion efficiency, large attenuation coefficient to X-ray source, high spatial resolution imaging, and great mobility-lifetime product ($\mu\tau$).¹⁻³ Compared to commonly used materials such as CdZnTe (CZT), CsI, and a-Se, perovskite detectors exhibit several orders of magnitude higher sensitivity, superior detection limits, and much better resolution. These properties make perovskite

detectors ideal for mechanical diagnosis, security screening, and other fields.⁴⁻⁶ A satisfactory perovskite X-ray detector is typically characterized by several essential properties, including adequate thickness to ensure efficient X-ray absorption, excellent optoelectronic properties for high sensitivity detection, and high stability in the operating environment. Furthermore, for commercial flat imaging applications, the perovskite detectors must possess scalability that are sufficiently large to match the size of the object under inspection.⁷⁻⁹

However, it is currently challenging to produce millimeter-thick large-area films using traditional deposition techniques or blade coating. On the other hand, the production of perovskite single crystal detectors is restricted by immature technology and high costs, particularly for the low-dimensional perovskite crystals.^{10, 11} Due to its highly tunable nature and cost-effective production processes, the fabrication of perovskite wafers represents a simple and commercially viable approach for developing X-ray detectors.¹² This method can be easily scaled up using molds or patterns, making it preferable to single crystals. The properties of perovskite wafer devices endow them with high competitiveness for commercial products and applications. Shrestha et al. first reported a room-temperature sintering process to fabricate thick MAPbI₃ wafer with a sensitivity of 2,527 $\mu\text{C Gy}_{\text{air}}^{-1} \text{cm}^{-2}$.¹³ Tie et al. have published findings on the operational stability and high sensitivity of (0D) MA₃Bi₂I₉ polycrystalline pellets.¹⁴ Similarly, Tang et al. fabricated a pinhole-free and high-performance Cs₂AgBiBr₆ wafer using the hot-pressing method as well.¹⁵ Previous studies have demonstrated the successful fabrication of thick perovskite wafers with remarkably high sensitivity, surpassing that of commercial α -Se detectors, and validating the practicality of them for X-ray detection.

However, a significant challenge facing the development of perovskite detectors is the uncontrollable migration of ions, high dark carrier concentration, and phase separation observed. The emergence of numerous cracks and voids porosities in the wafers leads to more severe ion migration, accelerates the decomposition of perovskite, and interferes with the signal collection, potentially hindering the growth of perovskite

detectors and cancelling their potential advantages.¹⁶⁻¹⁸ Moreover, despite their advantageous optoelectronic properties, traditional 3D hybrid perovskite single crystals, and wafers are still dominated by unstable methylammonium (MA) and formamidinium (FA) A-site cations. The propensity for these cations to decompose or undergo phase separation in 3D hybrid perovskites leads to device stability issues, thereby impeding the long-term reliability of perovskite-based devices.¹⁹⁻²¹

In this study, a high-performance perovskite derivative X-ray detector with excellent stability was developed. Specifically, a highly compact wafer for X-ray detection was fabricated using 1D δ -FAPbI₃ (yellow phase) for the first time. The low-dimensional structure of the δ -FAPbI₃ results in a high activation energy (E_a) for ion migration, which naturally offers high stability. The δ -FAPbI₃ precursor powders exhibit low Young's modulus and high internal homogeneity. Consequently, the wafers obtained by the cold isostatic pressing method have low porosity, low residual stress and fewer defect. This, in turn, effectively limits ion migration and improves charge transport properties. As a result, the wafer detector device exhibits a high sensitivity of 590.6 $\mu\text{C Gy}_{\text{air}}^{-1} \text{cm}^{-2}$ under 50 kV X-ray, excellent long-term stability of 6 months under ambient atmosphere, and an ultralow dark current drift of $3.43 \times 10^{-4} \text{ pA cm}^{-1} \text{ s}^{-1} \text{ V}^{-1}$. Notably, we demonstrated that the δ -FAPbI₃ wafers could be integrated with TFT readout arrays and realized direct 2D multipixel X-ray imaging.

Results and discussions

δ -FAPbI₃ precursor powders for wafers

Polycrystalline powders of δ -FAPbI₃ were fabricated by the wet-chemical reaction of FAI and PbI₂ at room temperature. As illustrated in Fig. 1a, with the surface-active sites of PbI₂ and FAI particles continuously colliding and initiating further chemical reactions, δ -FAPbI₃ polycrystals can be obtained. Scanning electron microscopy (SEM) shows that the synthesized yellow δ -FAPbI₃ powders have a rod-shaped blocks structure with a wide distribution of particles sizes from 1 to 70 μm (Fig. 1b, S1). The energy dispersive spectroscopy (EDS) mapping profile for a single block demonstrated

the uniform distribution of C, N, I and Pb elements (Fig. S2). The tail of the rod structure was cracked into ultra-fine single crystals under the effect of prolonged ultrasound (Fig. 1c, Fig. S3), and HRTEM revealed clear lattice fringes with interplanar spacing of 0.271 nm along the long axis, which matches with the (022) lattice spacing of δ -FAPbI₃ (Fig. 1d).²²

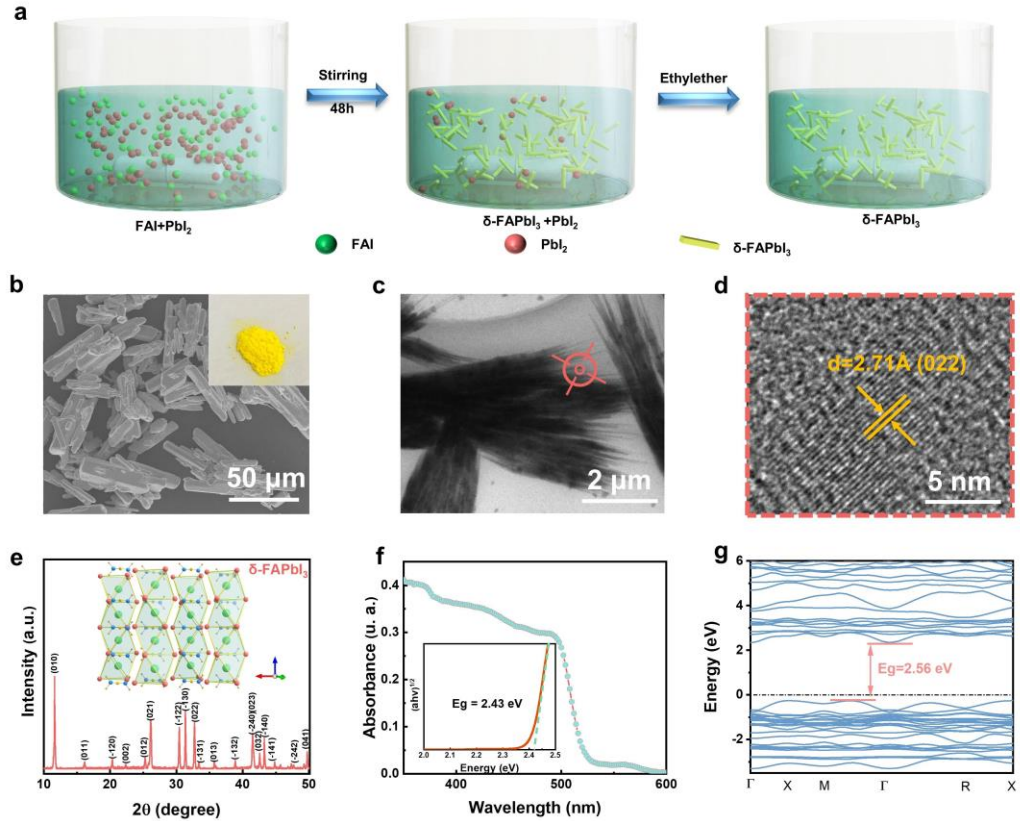


Figure 1. Fabrication and characterization of 1D δ -FAPbI₃ polycrystalline powders. (a) Schematic of δ -FAPbI₃ polycrystalline powders synthesized processing. (b) SEM and optical(inset) images of δ -FAPbI₃ polycrystalline powders, (c) TEM and (d) HRTEM images of δ -FAPbI₃ polycrystalline powders. (e) XRD pattern of δ -FAPbI₃ polycrystalline powders and its crystal structure (inset); (f) Absorption spectrum of δ -FAPbI₃ with its Tauc plot (inset) (g) Calculated electronic band structure of δ -FAPbI₃.

To investigate the structural properties of the powders, X-ray diffraction measurements were performed. As shown in Fig. 1e, the diffraction peaks of δ -FAPbI₃

powders at 11.6°, 26.2°, 30.5°, 31.4° and 32.7° are related to the lattice planes (010), (021), (-122), (-130) and (022), respectively, which fits well with the hexagonal system (P6₃mc space group) with unit-cell parameters of $a = b = 8.6603 \text{ \AA}$ and $c = 7.9022 \text{ \AA}$.²³ It demonstrated that pure δ -phase FAPbI₃ powders were obtained without PbI₂ residues. The inset illustration presents the δ -FAPbI₃ structure with face-sharing octahedra growing along the (001) direction to form single chains.²⁵ The FA⁺ cation occupies the space between the chains, resulting in a 1D crystal structure and presenting the potential for suppressing ion migration. Optical absorption spectra of δ -FAPbI₃ powders shows the absorption edge at approximately 520 nm, demonstrating a suitable optical band gap of 2.43 eV for an X-ray detector (Fig. 1f).^{10, 26} DFT calculations were further conducted to evaluate the electronic band structure of δ -FAPbI₃. The band gap of frontier molecular orbital was revealed by projected density of states (PDOS). Fig. S4 showed that the valence band maximum (VBM) of the δ -FAPbI₃ is mainly constituted of I 5p and Pb 6s contributions, and the conduction band minimum (CBM) is dominated by Pb 6p. Overall, the electronic band structure (Fig. 1g) shows that δ -FAPbI₃ is an indirect band gap semiconductor with a band gap of 2.56 eV. The bandgap discrepancy between experimental and theoretical calculations is mainly owing to a strong spin-orbit coupling (SOC) effects introduced by heavy Pb constituent²⁷.

Structural and mechanical investigations

To compare with the widely used cubic black phase FAPbI₃ (α -FAPbI₃)²⁸, α -FAPbI₃ polycrystalline particles with an average diameter of 0.5-8 μm were also prepared (Fig. S5, 6). Because of the one-dimensional hollow tube structure of δ -FAPbI₃ SCs (Fig. S7), it is obviously difficult to make the required detector based on these small fragile SCs, let alone orderly assemble these onto large flat-panel arrays for imaging. Here, cold isostatic-pressing technique was adopted to fabricate millimeter-thick FAPbI₃ wafers.¹⁴ Fig. 2a illustrates the fabrication procedure. The pre-prepared powders were compacted at a pressure of 0.2 G Pa for 10 min, and then the two wafers were got as shown in Fig.

S8. Interestingly, the α -FAPbI₃ wafer exhibits the same black color as the precursor powder, while the δ -FAPbI₃ wafer has an orange-red color rather than the yellow one of the precursor powders. This color change is mainly due to the piezochromism property of δ -FAPbI₃.²⁹ The pressure-induced the optical absorption spectra of δ -FAPbI₃ slightly red-shifted, and the corresponding band gap decreases from 2.43 eV for precursor powders to 2.38 eV for δ -FAPbI₃ wafer (Fig. S9). Meanwhile, the XRD pattern of both wafers showed the same characteristic peaks as for the precursor powders (Fig. S10), demonstrating that both phases maintain their original crystallized phase after cold isostatic-pressing treatment.

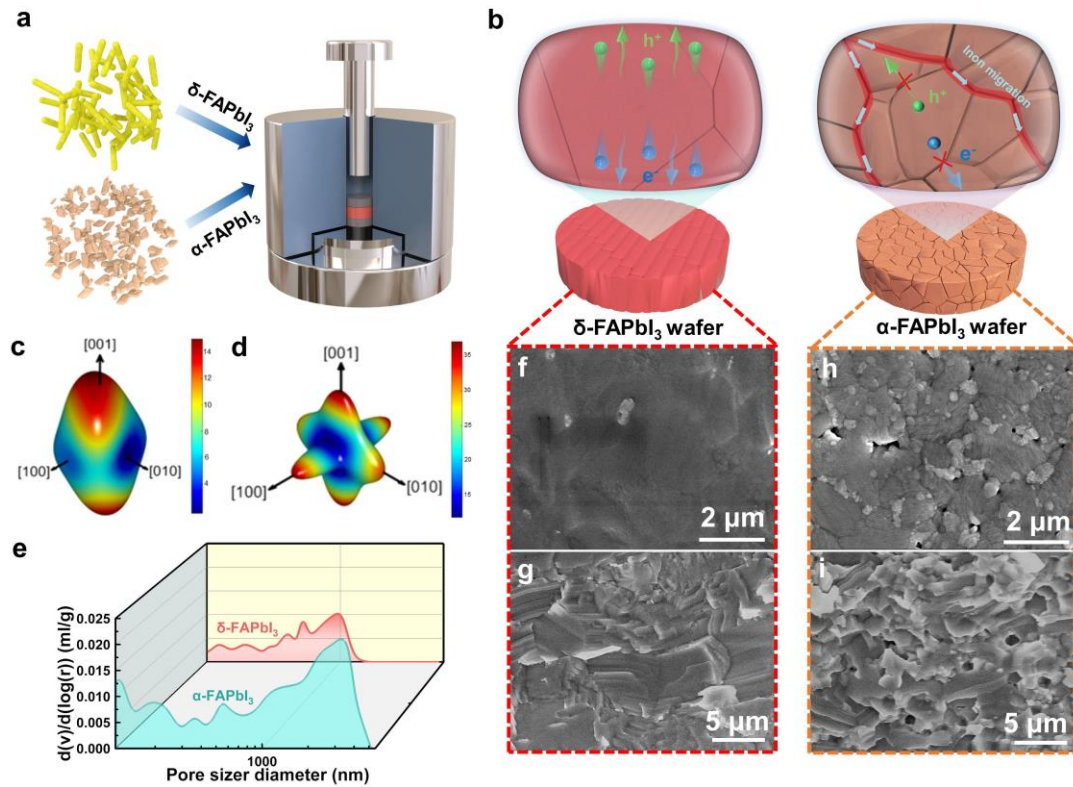


Figure 2. Preparation and characterization of δ -FAPbI₃ and α -FAPbI₃ wafers (a) Cold isostatic-pressing method to fabricate δ -FAPbI₃ and α -FAPbI₃ wafers. (b) Schematic illustration for the structure of δ -FAPbI₃ and α -FAPbI₃ wafers. (c) Surfaces of Young's modulus of the δ -FAPbI₃ and (d) α -FAPbI₃. (e) Differential pore size distribution of the δ -FAPbI₃ and α -FAPbI₃ wafers measured

by MIP; (f) Top view and (g) cross-sectional SEM images of the δ -FAPbI₃ wafers; (h) Top view and (i) cross-sectional SEM images of the α -FAPbI₃ wafers.

Fig. 2c, d shows the value of Young's modulus of the δ -FAPbI₃ and α -FAPbI₃ precursor powders, evaluated within Voigt–Reuss–Hill (VRH) approximation via DFT calculations.^{30, 31} Table S1 shows that the modulus along all directions of δ -FAPbI₃ crystal (7.93-4.49 GPa) is significantly smaller than that of the α -FAPbI₃ (23.91-17.70 GPa). This discrepancy could be attributed to the lower interchain stiffness and structural symmetry of hexagonal phase δ -FAPbI₃ than that of the 3D framework of cubic phase α -FAPbI₃.^{30, 32} Meanwhile, we also performed the nanoindentation measurement on the δ -FAPbI₃ and α -FAPbI₃ wafers (Fig. S11). The results show that the Young's modulus and hardness of δ -FAPbI₃ is 6.01 G Pa and 0.21 G Pa, respectively. The α -FAPbI₃ have a higher Young's modulus for 13.89 G Pa and hardness for 0.48 G Pa, which is in a good agreement with DFT calculation result. The mechanical properties of FAPbI₃ determine the deformation response to external pressure, and further influences on the interparticle binding area and binding strength. It shows that that δ -FAPbI₃ has a lower stiffness and is vulnerable to deform, which is of benefit to get a high-quality wafer.³³ Moreover, benefiting from the lower Young's modulus of δ -FAPbI₃, we have demonstrated that the lower residual stresses in δ -FAPbI₃ wafers through $d\text{-sin}^2(\psi)$ method and finite element simulations. The low residual stress can help δ -FAPbI₃ wafer form a more compact structure and facilitate the long-term structural stability of the device (details see Fig. S12-14). Correspondingly, the mercury intrusion porosimetry (MIP) method was performed,³⁴ Fig. 2e showed that the pore size distribution in the δ -FAPbI₃ wafer is significantly smaller than that of the α -FAPbI₃ wafer. And the porosity of α -FAPbI₃ wafer (7.51 %) is more than twice that of δ -FAPbI₃ wafer (3.49 %), indicating superior compactness of δ -FAPbI₃ wafer.

The detailed micromorphology of the wafers was further investigated by SEM (Fig. 2f and Fig. S15). The δ -FAPbI₃ wafer exhibits a homogeneous and dense surface with less grain boundaries. The corresponding cross-sectional SEM (Fig. 2g) also shows that the large agglomerated blocks of δ -FAPbI₃ are tightly bound together, exhibiting a

compact and nonporous morphology. In contrast, the α -FAPbI₃ wafer has a rougher surface and smaller crystals with numerous holes between the grain boundaries (Fig. 2h, i).

Based on the above analysis, we propose schematic models of the two wafers (Fig. 2b): the δ -FAPbI₃ wafer with flat and compact structure ensured stable photo carrier transport and effective charge extraction, while the numerous voids and internal defects in α -FAPbI₃ wafer not only hamper the device collection efficiency, but also lead to severe ion migration, significant baseline drifting, and signal acquisition jamming. The better morphology of the δ -FAPbI₃ comes from the precursor. As the single crystal pre-assembly in the solution forms rod-shaped blocks, the δ -FAPbI₃ powder with wide particle size distribution tends to have better packing density (Fig. S16).³⁵ And the plastic deformation of the supple δ -FAPbI₃ powder during the pressing process is more conducive to forming compact wafers with less porosity and low residual stress. Additionally, high quality δ -FAPbI₃ wafers can be fabricated using a simple compressing process, avoiding the high temperature treatment widely used in other works,^{13, 15, 36} implying a great competitiveness in commercial applications.

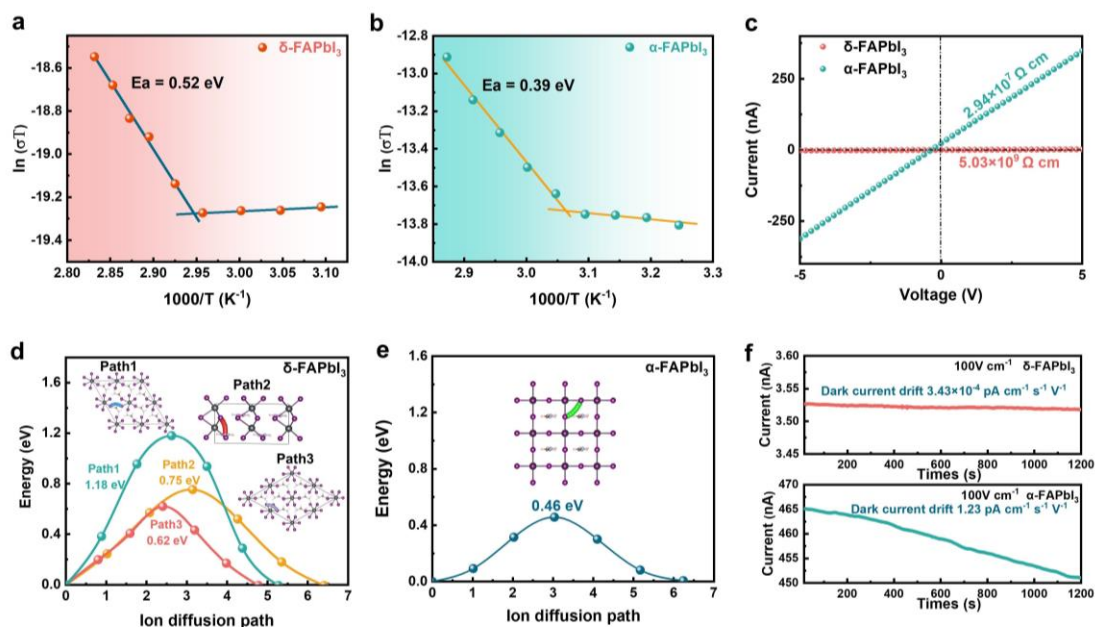


Figure 3. Ionic migration in δ -FAPbI₃ and α -FAPbI₃. Temperature-dependent conductivity of the (a) δ -FAPbI₃ wafer and (b) α -FAPbI₃ wafer. (c) The resistivity of δ -FAPbI₃ and α -FAPbI₃ wafers.

Calculated energy profiles along the different I⁻ ion-migration paths in (d) 1D δ -FAPbI₃ and (e) 3D α -FAPbI₃. (f) Dark current drift of the δ -FAPbI₃ and α -FAPbI₃ detectors at an electric field of 100 V cm⁻¹.

Ionic migration in the wafers

Previous reports have noted that ion migration inside wafer devices can lead to severe baseline drift and damage the crystal structure of the halide perovskite crystal, and correspondingly decrease the sensitivity of the detector and reduce the lifetime of the device.^{15, 16} To assess the ion mobility levels, we measured the conductivity of the wafers at different temperatures, and the activation energy (E_a) of ionic migration can be obtained by fitting the Nernst-Einstein relationship curve.¹⁴

$$\sigma(T) = \left(\frac{\sigma_0}{T}\right) \exp\left(-\frac{E_a}{k_B T}\right) \quad (1)$$

Where T is the temperature, $\sigma(T)$ is the conductivity, σ_0 is a constant, k_B is the Boltzmann constant and E_a is activation energy of ion conduction. As shown in Fig. 3 (a, b), with increasing temperature, the conductivity of δ -FAPbI₃ wafer remains almost constant at the low temperature stage, which refers to electronic conduction region. Then, the total conductivity of the δ -FAPbI₃ wafer shows a rapid increase when the temperature reached 340 K, corresponding to the ionic conduction being thermally activated and dominating the conductivity.³⁷ By measuring the slope of the conductivity dependence, the E_a of δ -FAPbI₃ wafer can be calculated as 0.52 eV, which is higher than that of α -FAPbI₃ (0.39 eV) and even MAPbI₃ (0.19 eV), indicating significantly lower ion migration in δ -FAPbI₃ wafer. Correspondingly, the resistivity of the δ -FAPbI₃ wafer is $5.03 \times 10^9 \Omega \text{ cm}$, which is higher than that of the α -FAPbI₃ ($2.94 \times 10^7 \Omega \text{ cm}$) (Fig. 3c), leading to lower dark current and further decreased detection limit.

We further investigated the differences of I⁻ ion-migration behavior in the 1D δ -FAPbI₃ and 3D α -FAPbI₃ via density functional theory (DFT). Several reports have shown that the ion migration in halide perovskite is dominated by I⁻ migration, resulting from the weak Pb-I bond and the short ion migration distance, whereas significant Pb²⁺ and FA⁺ migrations are less probable owing to their high activation energy.^{16, 38} Hence, we simulated three different paths of iodide ion migration to the nearby iodine vacancy in

1D δ -FAPbI₃ crystal cells using the climbing image nudged elastic band (CINEB) method. Each migration route was divided into seven steps (initial state, five inter-transition states and the final state), and the energy barrier is calculated from the difference between the total energies of initial state and the saddle point. Fig. 3d illustrates the energy barriers for the three possible migration paths in δ -FAPbI₃ are 1.18, 0.75 and 0.62 eV. One migration path in 3D α -FAPbI₃ was be considerate because the diffusion routes are isotropic (Fig. 3e), and the iodide ion energy barriers (0.46 eV) in α -FAPbI₃ is lower than that of 1D δ -FAPbI₃, indicating that the migration of I⁻ in 1D δ -FAPbI₃ is considerably inhibited. This can be explained by the fact that the face-sharing octahedra in δ -FAPbI₃ only propagating along the (001) orientation and disconnected to the other directions, thus leading to the ion migration channels being reduced compared to the three-dimensional structure.

Generally, high activation energy of ionic migration and high resistance can substantially enhance the stability of the δ -FAPbI₃ detector under a high electric field. As shown in Fig.3f, the long-term dark current of δ -FAPbI₃ and α -FAPbI₃ wafers exhibited significant differences. 1D δ -FAPbI₃ detector maintain a stable current baseline at ~ 3.53 nA for 1200 s under 100V cm^{-1} electric field, while the α -FAPbI₃ detector shows a noticeable baseline drift at ~ 460 nA. The following formulation was adopted to calculate the dark current drift:

$$I_{drift} = (I_t - I_0)/E \times S \times t \quad (2)$$

Where I_t and I_0 is the current at the ending and beginning state, E is the electric field and S is the detector area.³⁹ The calculated current drift of δ -FAPbI₃ detector was 3.43×10^{-4} pA $\text{cm}^{-1} \text{s}^{-1} \text{V}^{-1}$, and this ultra-stable baseline is almost comparable to that of a single crystal perovskite detector.³⁹ In contrast, α -FAPbI₃ detector exhibits 1.23 pA $\text{cm}^{-1} \text{s}^{-1} \text{V}^{-1}$ current drift, equivalent to previously reported MAPbI₃ (0.13 pA $\text{cm}^{-1} \text{s}^{-1} \text{V}^{-1}$), both of which are several orders of magnitude larger than that of δ -FAPbI₃ detector. This difference could be attributed to the low ion migration and highly compact structure of 1D δ -FAPbI₃ wafer.

Subsequently, the time-of-flight (TOF) method was employed to determine the carrier mobility (μ) of δ -FAPbI₃ wafers (see experimental section for details). With the excitation of a pulsed laser, the charge drift time (t_{tr}) can be obtained by analyzing the pulse height rise time distribution, and the mobility can be calculated from the formulation: $\mu = d^2 / (V t_{tr})$, where d is the wafer thickness and V is the bias.⁴⁰ The typical TOF results are shown in Fig. S17 and S18, the hole and electron mobility of the δ -FAPbI₃ wafer are 2.07-5.92 cm² V⁻¹ s⁻¹ and 2.41-6.54 cm² V⁻¹ s⁻¹, respectively. And the comparable value of μ for electrons and holes indicates an ambipolar charge transport in δ -FAPbI₃ wafers (Fig. S19).

For practical applications, the stability of the semiconductor in air atmosphere is also a key property. The thermodynamic stability of α -FAPbI₃ and δ -FAPbI₃ were examined by DFT calculating (Table S2). The binding energies were calculated to be -0.414 eV and -0.422 eV per atom for α -FAPbI₃ and δ -FAPbI₃, respectively. Suggesting that δ -FAPbI₃ has a more stable thermodynamically stable structure. Correspondingly, as shown in Fig. S20, the δ -FAPbI₃ wafer shows no significant changes in the XRD patterns after exposure for 6 months in ambient air with a relative humidity of $\approx 70 \pm 5\%$, demonstrating superior environmental stability.⁴¹

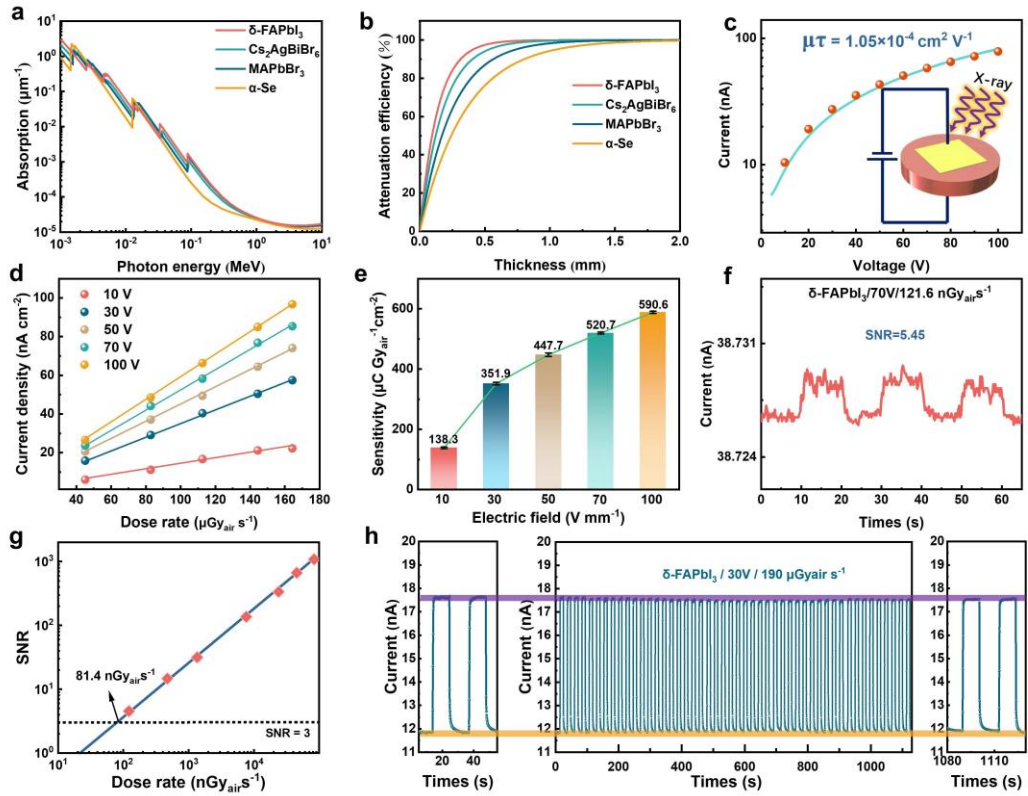


Figure 4. X-Ray detection performance of the δ -FAPbI₃ wafer detectors. (a) Absorption coefficients of δ -FAPbI₃, Cs₂AgBiBr₆, MAPbBr₃ and α -Se as a function of photon energy; (b) Attenuation efficiency of δ -FAPbI₃, Cs₂AgBiBr₆, MAPbBr₃ and α -Se for 40 keV X-ray photons versus thickness; (c) Bias-dependent photoconductivity of the Au/ δ -FAPbI₃/Au device and the derived $\mu\tau$ value under X-ray; (d) Signal current densities as a function of dose rate at different applied electric fields under X-ray; (e) Sensitivity under different electric field of the δ -FAPbI₃ wafer X-ray detector; (f) X-ray response characteristics of the δ -FAPbI₃ detector under an ultralow X-ray dose rates ($121.6 \text{ nGy}_{\text{air}} \text{ s}^{-1}$) at 70 Vmm^{-1} electric field; (g) Dose rate dependent SNR of the δ -FAPbI₃ detector; (h) Stability of the X-ray response of the δ -FAPbI₃ detector.

Performance of X-ray detectors

High resistivity, low ion migration, stable current baseline and long-term stability are essential for high-performance photodetectors, as aforementioned analysis, 1D δ -FAPbI₃ wafer was qualified and a promising candidate for commercial X-ray detector.

With the aim of fabricate high quality X-ray detectors, it is essential to select the optimum thickness to ensure sufficient absorption of X-rays, yet minimize the transmission distance of photocarriers. Here, the continuum bremsstrahlung X-ray equipment operated at a voltage of 50 kV, and the mean energy was calibrated as 33.93 keV (Fig. S21). The absorption coefficients of perovskites and traditional semiconductors are obtained from the NIST database, the absorption coefficient of FAPbI₃ is close to that of the double perovskite Cs₂AgBiBr₆ while higher than that of MAPbBr₃ and a-Se (Fig. 4a).⁴² The high absorption coefficient corresponds to the high attenuation coefficient, which supports that 0.8 mm thickness of FAPbI₃ can attenuate 99.7 % of the 40 keV X-ray photons (Fig. 4b). For guarantying sufficient X-ray absorption, the 0.8 mm thickness wafer is selected and assembled it into vertical structure (Au/ FAPbI₃ /Au) for further testing.

Mobility-lifetime products ($\mu\tau$) is a key parameter to estimate a semiconductor's capability of extracting charge, we thus recorded the photoconductivity of δ -FAPbI₃ wafer under a 50 kV_p X-ray excitation source, and obtained the $\mu\tau$ product by fitting with the Hecht equation. As exhibited in (Fig. 4c), δ -FAPbI₃ wafer held a $\mu\tau$ product of $1.05 \times 10^{-4} \text{ cm}^2 \text{ V}^{-1}$, which is close to 3D MAPbI₃ wafers ($2 \times 10^{-4} \text{ cm}^2 \text{ V}^{-1}$) and slightly lower than Cs₃Bi₂I₉ single crystal detector ($7.97 \times 10^{-4} \text{ cm}^2 \text{ V}^{-1}$), while superior to the a-Se ($10^{-7} \text{ cm}^2 \text{ V}^{-1}$).^{13, 42, 43}

Besides, the on/off photocurrent response under various electric fields (from 10 to 100V) and dose rates (45.1-192.4 $\mu\text{Gy}_{\text{air}} \text{ s}^{-1}$) are listed in Fig. S22-24, respectively. It can be concluded that the δ -FAPbI₃ detector has steady current signal and good reproducibility. Meanwhile, the generated photocurrent density scaled linearly with the X-ray dose rate (Fig. 4d). And the sensitivity of the δ -FAPbI₃ wafer detector under different biases can be calculated by fitting the slope of the photocurrent density-dose rate curves. As shown in Fig. 4e, with the increase of electric field from 10 to 100 V mm⁻¹, the sensitivity of the detector shows an increasing trend, owing to the higher electric field contributing to better charge collection. Under 100 V mm⁻¹ field, the δ -FAPbI₃ wafer detector can reach a sensitivity of $590.6 \mu\text{C Gy}_{\text{air}}^{-1} \text{ cm}^{-2}$, which is almost

thirty times higher than that for the a-Se X-ray detectors ($20 \mu\text{C Gy}_{\text{air}}^{-1} \text{cm}^{-2}$ at a higher field of $10 \text{ V } \mu\text{m}^{-1}$).⁴⁴

In addition to the sensitivity, the LoD is also a crucial parameter for evaluating the detectors performance, Fig. 4f shows the response of the $\delta\text{-FAPbI}_3$ wafer detector under X-ray dose rates of $121.6 \text{ nGy}_{\text{air}} \text{ s}^{-1}$ at 70 Vmm^{-1} electric field, and the signal to noise ratios (SNR) of detector is calculate as 5.45, indicating its high detection efficiency at low radiation doses. Effective detection required the generated signal three times higher than the noise level.⁴⁵ By fitting the SNR at various radiation doses (Fig. 4g), we obtained the LoD of $81.4 \text{ nGy}_{\text{air}} \text{ s}^{-1}$, which is much lower than the requirement of conventional medical diagnostics ($5.5 \mu\text{Gy}_{\text{air}} \text{ s}^{-1}$). The comparison of the $\delta\text{-FAPbI}_3$ detector with other perovskite-based wafer devices reported previously was list in Table S3. What's more, Fig. 4h shows the response of $\delta\text{-FAPbI}_3$ wafer detector under on/off X-ray radiation for long term testing. The $\delta\text{-FAPbI}_3$ detector presents steady current signal with no photocurrent signal attenuation or baseline current drift, and there is almost no degradation in response current for $\delta\text{-FAPbI}_3$ wafer aging for 6 months (Fig. S25), demonstrating its great operational and irradiation stability.

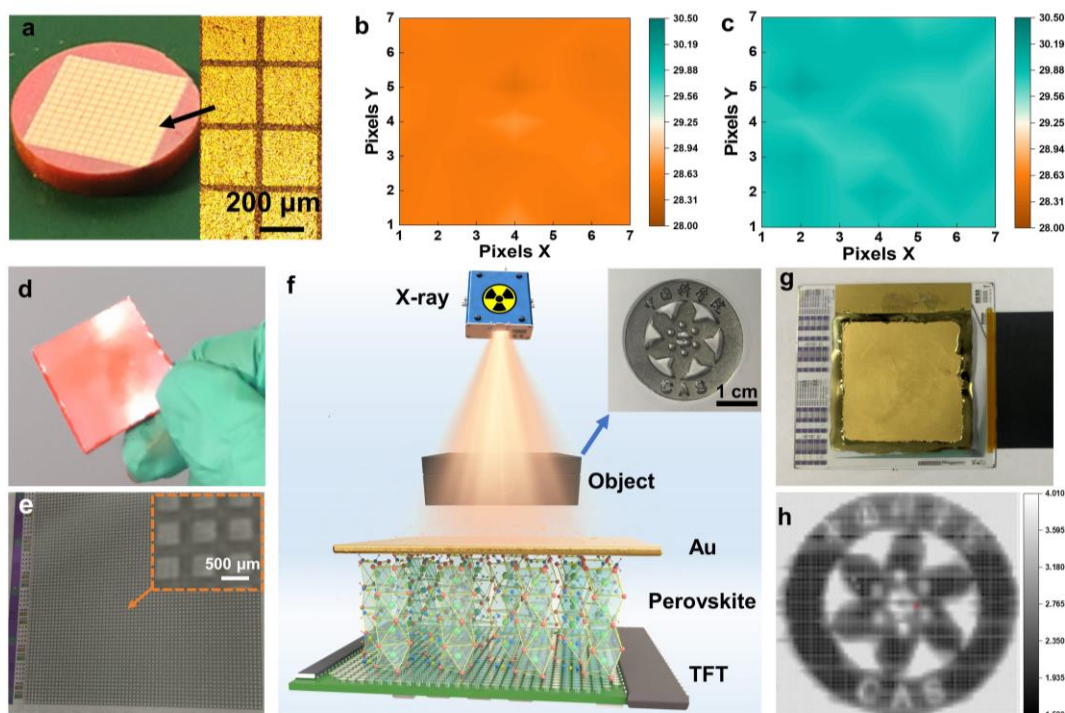


Figure 5. X-Ray imaging performance of the δ -FAPbI₃ wafer detectors: (a) The prepared 14×14 pixels wafer-based detector; (b) Mapping of dark current and (c) photocurrent; (d) Fabrication of 3×3 cm δ -FAPbI₃ wafer by cold isostatic-pressing; (e) Microstructure of the 64×64 pixels TFT backplane, the pixel pitch is 500 μ m; (f) Schematic illustration of the X-ray imaging process using a δ -FAPbI₃ wafer X-ray imaging detector, the inset is the optical image of tested object; (g) Photograph of the final flat-panel X-ray imaging detector. (h) X-ray imaging of the “Chinese Academy of Sciences” logo.

X-ray imaging performance

The uniformity of the detector determines the clear distinction of gray levels, which is directly related to the quality of imaging.¹⁵ In order to test the uniformity of the δ -FAPbI₃ wafer device, we prepared a 14×14 pixels detector using the laser cutting method (Fig. 5a), in which a 7×7 pixels array was selected for testing responses under dark and light conditions. Fig. 5b and c showed the value of dark current as 28.51 ± 0.05 nA and of photocurrent as 29.89 ± 0.08 nA, respectively. The standard deviation of dark and light signals is both much lower than the value of signal current, proving a good uniformity of the wafer device. Then the modulation transfer function (MTF) of the δ -FAPbI₃ wafer was measured, as shown in Fig. S26, the resolution of δ -FAPbI₃ wafer is 4.0 at MTF=20%, demonstrating its excellent imaging capability and is capable for millimeter scale imaging.

We further assembled pixels array detector to realize direct flat panel radiographic imaging. A 3×3 cm size of δ -FAPbI₃ wafer with 0.8 mm thickness was fabricated by cold isostatic-pressing (Fig. 5d) with good flatness and gloss, implying the upgradeability of this method. Subsequently, the wafer was integrated as a photoconductor with a 64×64 pixels thin film transistor (TFT) backplane (Fig. 5e), using an electronic bonding agent around the wafer for fixing. The prepared flat-panel direct detectors (Fig. 5g) were further applied to radiography imaging. As illustrated in Fig. 5f, the X-rays emitted by the ray tube will be absorbed when they pass through the metal sample object, and the pixel electrodes at different positions will receive a different photo response current. The electrical signals are collected by the matrix

electrodes and exported to external devices through the readout circuit. Ultimately, the shape characteristics of the object can be obtained by analyzing the electrical signal intensity distribution. As a result, the radiograph offers a detailed view of the metal sample with a sufficient resolution to clearly recognize the characters (Fig. 5h).

Conclusion

In summary, we developed a high-performance X-ray wafer detector, and found the hexagonal δ -FAPbI₃ perovskite derivative has significantly low ionic migration, low Young's modulus and excellent long-term stability, which allow us to prepare a highly compact and low residual stress wafer for high-performance X-ray detector. As a result, the detector showed an ultralow dark current drift of 3.43×10^{-4} pA cm⁻¹ S⁻¹ V⁻¹, combined with a low detection limit of 81.4 nGy_{air} s⁻¹ and long-term stability. The device achieved high sensitivity of 590.6 μ C Gy_{air}⁻¹ cm⁻² under 50 kV_p X-ray, which is about thirty times higher than that of commercial a-Se X-ray detectors. Notably, the δ -FAPbI₃ wafer detector enables direct multi-pixel X-ray imaging by integrating a large size δ -FAPbI₃ wafer with TFT backplane. The high stability, good detection performance, and outstanding X-ray imaging property of 1D δ -FAPbI₃ render it a highly promising candidate for X-ray detection. Our findings also suggest the preparation of multi-pixel wafer X-ray imaging detector has immense potential for commercial X-ray detector application.

Methods

Synthesis of FAI

Formamidinium iodide (FAI) was synthesized by reacting formamidine acetate (0.1 mol, 98%) with hydriodic acid (0.1 mol, 57 wt% in water, sigma-aldrich) in a flask and were stirred at 0 °C for 2 h. The yellow powder was obtained by evaporation of the solvent

at 60 °C for 1 h. Then the product was recrystallized three times by dissolving in ethanol, and cleaned by diethyl ether. The resulting product was dried in a vacuum oven for 24h.

Fabricate of α -FAPbI₃ powders

The α -FAPbI₃ powders were synthesized by a solvent evaporation method. PbI₂ (1.537 g) and FAI (0.47 g) were dissolved in 15ml γ -butyrolactone (GBL), and the precursor solution was put into a glass beaker and kept stirring for 3 h. The beaker was then placed on a heating table at 150 °C, the black α -FAPbI₃ powder was obtained with the dissolved evaporation totally. The resulting product cleaned by diethyl ether 6 times and completely dried at 40 °C in a vacuum oven for 12h.

δ -FAPbI₃ wafers Fabrications

The massive bulky single-crystal aggregates were synthesized by wet chemistry reaction based on antisolvents. 1.537 g PbI (99.99%, Alfa Aesar) and 0.47 g FAI were mixed by grinding, then the mixture was added in to 20 ml sample bottles containing 15 mL acetonitrile (ACN) and stirred at high speed for 30 h. The resulting product was cleaned with diethyl ether for 6 times and completely dried at 40 °C in a vacuum oven for 12 h. The δ -FAPbI₃ powders were then placed into the 5×5 mm mold, which was pressed at 200 MPa for 20 min, and high quality δ -FAPbI₃ wafers with high density and low porosity can be obtained. The larger sized 3×3 cm δ -FAPbI₃ wafer was fabricated in the same way. The same cold isostatic compression conditions were used to prepare 5×5 mm α -FAPbI₃ wafers as control samples

Device fabrication

Au/ δ -FAPbI₃ wafers/Au devices were employed for X-ray detection measurements. The Au electrodes (80 nm) with a size of 3×3 mm was deposited vertically on the top and bottom of the perovskite wafer by thermal evaporation, the thickness of the wafer was 0.8 mm for sufficient absorption of the 50 keV X-ray. For the TOF measurements, the 3×3 mm Au charge-collecting electrodes with thicknesses of 40 and 80 nm were

thermally evaporated on both sides of the δ -FAPbI₃ wafers (1 mm), respectively, and the thin side was used as the semitransparent electrode for light transmission.

Materials Characterization

X-ray diffraction (XRD) patterns of the perovskite were performed with a Rigaku Smartlab 9 kW diffractometer with Cu K α radiation. Morphologies of the perovskite powder and wafer were characterized by scanning electron microscopy (SEM, Hitachi SU8020) with a Schottky Field Emission gun, High resolution transmission electron microscope TEM (HRTEM) operated at 200 kV was used for further Structural morphology analysis. Mercury intrusion porosimetry (MIP) was used to measure porosities of the perovskite wafers. Absorption spectra and Steady-state photo luminescence (PL) spectra were measured using ultraviolet (UV) spectrophotometer (U-3900H) and spectrofluorometer (Photon Technology International), respectively. High precision micrometer was used to measure the thickness of the wafers. The Nanoindentation was performed on a in-situ nanomechanical test system (TI-950, HYSITRON).

Hole and electron mobilities measured

Hole and electron mobilities were measured by the time-of-flight (TOF) method, A pulsed laser with 532 nm wavelength and 6 ns width was illuminated on the 40 nm semitransparent Au electrode of the device. A Keithley digital source meter (Model 2400) was used to apply a bias to the sample and the photocurrent was recorded with a low-noise current preamplifier (SR570, Stanford Research Systems). When the 40 nm semitransparent Au electrode is used as the cathode, the hole mobility can be calculated based on the transition time of the photogenerated holes between the opposite electrodes. Similarly, when this electrode is used as the anode, the electrons mobility can be calculated based on the transition time of the photogenerated electrons between the opposite electrodes.

X-ray detection Measurement and imaging

We chose a tungsten anode X-ray tube with ~ 2.5 mm Al filter as the source to investigate the X-ray detection performance. The X-ray source worked under a constant 50 kV voltage and modulated the radiation dose rate by changing the tube current (0.2-0.5 mA). Further, X-ray dose rate was calibrated using a Radcal Accu-Dose⁺ 10 \times 6-180 dosimeter. The I-t characteristics were measured with a Keithley 6517b source meter operated by Wu Han ZY Technology software. All tests were performed in an anti-radiation lead box, in order to decrease electromagnetic signal effects and interference from ambient light. For X-ray imaging, a 3 \times 3 cm size δ -FAPbI₃ wafer was integrated onto the TFT substrate backplane (the TFT backplane and readout circuit system were provided by LinkZill), followed by fixing the wafer with electronic adhesive and curing under 5 mPa for 24 hours. Finally, the top surface of the device was covered with 100 nm gold as the top electrode. The flat-panel detector was worked under 192.4 $\mu\text{Gy}_{\text{air}} \text{s}^{-1}$ dose rate with 10V bias for imaging, The sample size of pixel value distribution in detector was 4096, each pixel has a grayscale value between 0 and 255.

Computational details

First-principle calculations in this work were performed in the framework of the density functional theory (DFT) with the projector augmented plane-wave method, as implemented in the Vienna ab initio simulation package (VASP). The generalized gradient approximation proposed by Perdew–Burke–Ernzerhof (PBE), is selected for the exchange-correlation potential. The cut-off energy for a plane wave is set to 500 eV. The energy criterion is set to 10^{-5} eV in the iterative solution of the Kohn-Sham equation. The Brillouin zone integration is performed using a 5 \times 5 \times 5 k-mesh. All the structures are relaxed until the residual forces on the atoms have declined to less than 0.02 eV/Å. The energy barriers for I ion diffusion in the perovskite were computed by the nudged elastic band (CI-NEB) method with 5 images. **The Finite Element Model (FEM) analysis was conducted using COMSOL Multiphysics, and the residual stress distribution within wafers was assessed based on Density-dependent Drucker–Prager Cap (DPC) model.**

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Author contributions

J.Y. and X.P. conceived the idea and supervised the project. Z.W. designed the experiments. Z.W. and S.T. carried out material preparation, characterizations and device fabrication. Z.W., H.Z. and C.W. set up the measurement facilities for the X-ray detector and photodetector. Z.W., S.T. and H.Z. measured the detector optoelectronic characterizations, X-ray detector response and imaging. Z.L. and H.X. assisted with the measurement and discussions. J.Y. and Z.W. co-wrote the manuscript, and X.Z., A.D. and R.P. provided the revisions. All the authors reviewed the paper.

Competing interests

The authors declare no competing interests

Additional information

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